

Bulk and Surface Contributions to Ionisation Potentials of Metal Oxides

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Abstract: Determining the absolute band edge positions in solid materials is crucial for optimising their performance in wide-ranging applications including photocatalysis and electronic devices. However, obtaining absolute energies is challenging, as seen in CeO₂, where experimental measurements show substantial discrepancies in the ionisation potential (IP). Here, we have combined several theoretical approaches, from classical electrostatics to quantum mechanics, to elucidate the bulk and surface contributions to the IP of metal oxides. We have determined a theoretical bulk contribution to the IP of stoichiometric CeO₂ of only 5.38 eV, while surface orientation results in intrinsic IP variations ranging from 4.2 eV to 8.2 eV. Highly tuneable IPs were also found in TiO₂, ZrO₂, and HfO₂, in which surface polarisation plays a pivotal role in long-range energy level shifting. Our analysis, in addition to rationalising the observed range of experimental results, provides a firm basis for future interpretations of experimental and computational studies of oxide band structures.

Introduction

The ionisation potential (IP), electron affinity (EA), and work function (Φ) are fundamental quantities of metal oxides governing electronic, optical and transport processes. While isolated molecules have well-defined IPs and EAs that can be accurately measured or calculated using experimental and computational techniques,^[1] obtaining the absolute band-edge positions in solids with respect to the vacuum level is far more challenging. In the solid state, these quantities become surface-related parameters, and experimental measurements on the same material can exhibit significant variations due to different morphologies and processing histories.^[2]

Compared to the highly variable nature of Φ ,^[3] the surface sensitivity of IP in metal oxides remains less clearly understood. An intriguing case is provided by ceria (CeO₂), which has a wide range of applications in heterogeneous catalysis.^[4] Recently, Wardenga and Klein^[5] reported IPs of undoped CeO₂ thin films prepared using radio frequency magnetron sputtering. Surprisingly, the measured IPs on different samples varied from 6.5 to 9.1 eV, which is a substantial scatter compared with other oxides prepared with similar techniques.^[3,6] Significant variations (from 5.47 eV to 7.7 eV)^[7] are also observed in measurements on other CeO₂ samples (Table S1). A possible origin for the IP variation in CeO₂ is its highly variable surface chemistry,^[5] which can release and store oxygen repeatedly in redox cycles.^[8] However, such a significant variation is not seen in other easily reducible oxides, indicating that some other previously unaccounted for factors play a significant role.

Here, we combine several computational approaches: classical electrostatic analyses, hybrid quantum mechanics/molecular mechanics (QM/MM) embedded-cluster simulations,^[9] and plane-wave density functional theory (DFT) calculations,^[10] to disentangle the origins of the highly variable IP of CeO₂. We separate the bulk and several sources of surface contributions to the IP using theoretical models, elucidating another cause of uncertainty in experimental measurements apart from the variable surface chemistry. We find critical intrinsic surface effects in metal oxides, particularly prominent in CeO₂ and other high-dielectric-constant (high- κ) MO₂ oxides, where surface polarisation strongly affects the absolute band positions deep into the bulk. Our approach enables a clear and coherent approach to computational and experimental studies of this crucially important quantity for both ceria and other oxides.

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Results and Discussion

Surface polarisation mechanisms of metal oxides and effects on ionisation potential

We first compare cubic, fluorite structured CeO_2 with two rock-salt structured oxides, MgO and BaO , to understand how cationic properties affect the bonding environment and surface polarisation. First, periodic DFT calculations using the Vienna Ab-initio Simulation Package (VASP)^[10] at the PBE0^[11] level of theory were performed to compare charge densities in bulk and at their nonpolar surfaces (Figure 1a–c). In MgO , O^{2-} is much more diffuse than Mg^{2+} , and Mg^{2+} has a low polarisability, which we calculate as 0.48 a.u. in the gas phase. By contrast, Ce^{4+} has an over tenfold higher calculated polarisability of 5.87 a.u., in the gas phase associated with the more diffuse charge density of Ce^{4+} . Ba^{2+} has an even higher calculated polarisability of

10.42 a.u. and a large Shannon ionic radius,^[12] and the cation charge density in BaO is more diffuse than that of the anions.

To distinguish and quantify various sources of surface effects on energy-level shifting, we combined DFT calculations with electrostatic analyses supported by shell-model (SM) interatomic potentials^[13] as implemented in the General Utility Lattice Package (GULP),^[14] using the non-polar (Tasker Type 1)^[15] $\text{CeO}_2(110)$, $\text{MgO}(100)$, and $\text{BaO}(100)$ surfaces as typical examples.

In the SM, an ion is separated into a massless shell and an atomic core connected by a harmonic spring, parameterised to reproduce the ionic polarisability and hence dielectric constants. Here, we denote “Shell” as the frozen-nuclei surface slab model retaining the bulk geometry, where only electronic degrees of freedom are relaxed, representing the polarised electron structure due to surface termination. This state can be obtained from either a DFT

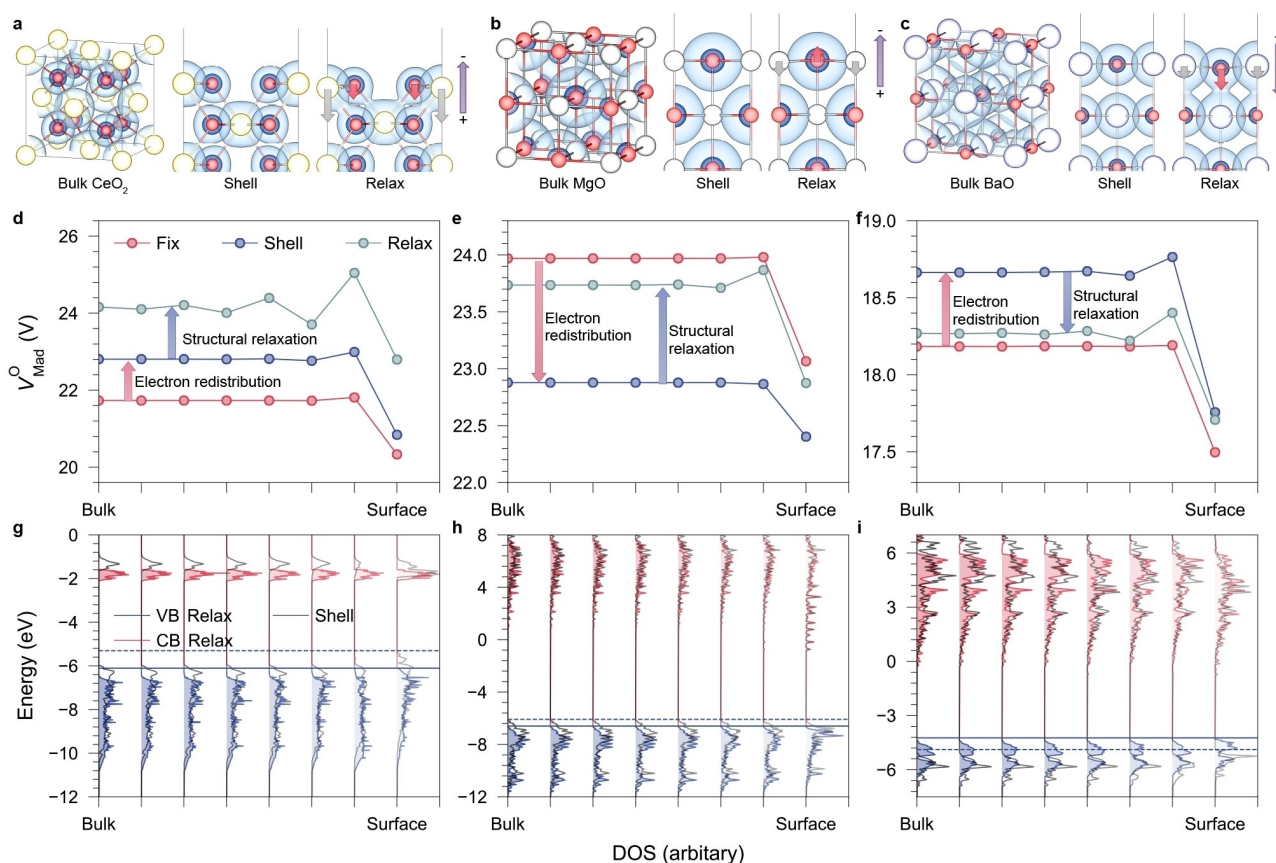


Figure 1. Effects of surface polarisation and structural relaxation on the ionisation potential: the case of the nonpolar $\text{CeO}_2(110)$, $\text{MgO}(100)$, and $\text{BaO}(100)$ surfaces. (a–c) Charge density in bulk calculated within the 3D periodicity, on nonpolar surfaces with fixed bulk geometry (denoted as “Shell”), and after structural relaxation (“Relax”). Red, yellow, white, and purple spheres indicate O, Ce, Mg, and Ba, respectively. The dark isosurface represents a level of $0.5 e/\text{Bohr}^3$, while the light blue isosurface is $0.08 e/\text{Bohr}^3$ for CeO_2 and $0.03 e/\text{Bohr}^3$ for MgO and BaO , respectively. Arrows indicate the relative displacements of surface ions after the structural relaxation, resulting in different types of surface rumpling, which suppress the ionisation on $\text{CeO}_2(110)$ and $\text{MgO}(100)$ but promote the ionisation on $\text{BaO}(100)$ due to the opposite directions of near-surface electrostatic fields. (d–f) The O-site electrostatic (Madelung) potentials from the bulk region to the surface, modelled by the shell model, showing the variation of the electrostatic environment due to initial electronic polarisation (from “Fix” to “Shell”) and further structural relaxation (from “Shell” to “Relax”). (g–i) The layer-by-layer density of states from bulk to surface confirms the shifts of the valence band edges before (dash lines) and after structural relaxation (solid lines) due to different mechanisms of surface rumpling. The intensities of the valence band of CeO_2 , the conduction bands of MgO and BaO have been magnified threefold for better clarity.

single-point calculation or shell relaxation using the SM. “Relax” represents the optimised geometry that further considers atomic core relaxation. Finally, the SM allows the investigation of the just-cleaved unpolarised state without electronic redistribution, in which the shells are fixed at the core sites as those in the bulk environment, thereby preventing the surface polarisation (denoted as “Fix”).

When a nonpolar surface of an ionic crystal is cleaved from the bulk, the net dipole moment is zero due to the complete cancellation of ionic charges in each atomic plane. Consequently, the nonpolar arrangement of atomic layers does not affect the electrostatic potentials on ions in the bulk at the “Fix” state, making it an ideal model for studying the contributions of electronic redistribution and atomic relaxation on surface-induced energy-level shifting. Although CeO₂(110) is not the most stable surface of ceria, it can be controllably synthesised in experiments, leading to enhanced activity in some particular catalytic reactions such as CO oxidation.^[16]

For the “Shell” state, DFT calculations on CeO₂(110) show deformed charge density on both surface Ce⁴⁺ and O²⁻ sites compared with the symmetrical distribution in the bulk (Figure 1a). The charge density on MgO(100) is also polarised but exhibits a lesser deformation. Figure 1d–f shows the variation of the calculated Madelung potential^[17] on oxygen core sites ($V_{\text{Mad}}^{\text{O}}$) from bulk to surface using the SM. The vacuum levels have been aligned to 0 V for a direct comparison of the absolute $V_{\text{Mad}}^{\text{O}}$ in various systems. In metal oxides, the valence band maximum (VBM) is dominated by the O 2p orbitals, and the IP is determined mainly by the balance between the local electrostatic environment (represented by $V_{\text{Mad}}^{\text{O}}$) and the second electron affinity of oxygen (A_{O}^2).^[2b] A_{O}^2 is a lattice-sensitive variable,^[18] but a higher $V_{\text{Mad}}^{\text{O}}$ indicates stronger electron binding to the atomic site and a higher IP. For CeO₂ and BaO, the electronic redistribution (from “Fix” to “Shell”) on their respective nonpolar surfaces increases $V_{\text{Mad}}^{\text{O}}$ on all anion sites across the slab; in contrast, $V_{\text{Mad}}^{\text{O}}$ under MgO(100) decreases after the electronic redistribution.

The shift of $V_{\text{Mad}}^{\text{O}}$ in the middle of the slab (D_s) from the “Fix” to “Shell” states has been used to evaluate the magnitude of surface polarisation, which serves as an appropriate correction to the DFT-based “core-level alignment” (CLA) method to evaluate the bulk IP (details in Supporting Information).^[19] For MgO(100), surface polarisation contributes +0.85 eV to the IP, yielding 6.89 eV after the D_s correction at the PBE0 level of theory, consistent with the experimental measurement of 7.15 eV.^[20] For CeO₂, the uncorrected CLA approach overestimates the bulk IP by 1.06 eV due to the opposite multipolar shift, resulting in 4.76 eV after the D_s correction. Similarly, a negative D_s correction (−0.61 eV) is observed in BaO, whose cation polarisability is also much higher than that of Mg²⁺. The group 2 rock-salt structured oxides share a similar in-lattice anion polarisability from 6.3 to 7.0 a.u. as calculated by an embedded-cluster model (Table S17), while cation polarisabilities vary substantially. For example, Ca²⁺, with a calculated polarisability of 3.27 a.u., has a positive but much lower D_s shift in CaO (+0.17 eV), compared to Mg²⁺ in

MgO. Sr²⁺ is more polarisable (calculated as 5.82 a.u.) and close to the in-lattice polarisability of O²⁻ in SrO, making the D_s shift (−0.06 eV) small. The impact of the cation-anion relative polarisability on surface polarisation can be understood by a single-layer atomistic model (Figure S1a). We calculated the shell displacement in response to a constant electric field with variable cation polarisability and lattice constant, for simulating the rock-salt structure (100) surface polarisation (Figure S1b). As the cation polarisability increases, the shell displacement on cations becomes more pronounced and gradually exceeds that on anions. Hence, on descending the group 2 oxides, cations play an increasing role in surface polarisation, transferring the D_s shift from positive to negative, and shifting the VBM accordingly in opposite directions.

Effects of surface rumpling

The variation of $V_{\text{Mad}}^{\text{O}}$ from “Shell” to “Relax” as seen in Figure 1d–f reveals the influence of structural relaxation on the electrostatic environment. Surface rumpling occurs on relaxation, i.e., surface ions are displaced by different amounts. On CeO₂(110), cations move further inwards than anions. On MgO(100), while Mg²⁺ moves inwards, O²⁻ protrudes beyond the original plane. The relaxed surfaces are both terminated by oxygen, consistent with previous theoretical and experimental studies.^[21] Structural relaxation results in an electrostatic field normal to the surface due to charge separation (Figure 1a–b). The electrostatic fields on MgO(100) and CeO₂(110) suppress the electron transfer into the vacuum, shown by the positive shift of $V_{\text{Mad}}^{\text{O}}$ from “Shell” to “Relax” in Figure 1d–e. However, surface rumpling on BaO(100) differs significantly: as anions move further towards the bulk than cations, an electrostatic field opposite to those on MgO(100) and CeO₂(110) is generated by the Ba-terminated topmost plane. This surface rumpling mechanism promotes the ionisation of electrons on BaO(100), in agreement with the negative shift of $V_{\text{Mad}}^{\text{O}}$ (Figure 1f). In Figure 1g–i, we present the layer-by-layer density of states before (dash lines) and after (solid lines) structural relaxation obtained by DFT calculations on slab models. Electronic-structure calculations confirm the shift of VBM from −5.31 eV to −6.11 eV for CeO₂(110) and from −6.08 eV to −6.60 eV for MgO(100) due to oxygen-terminated surface rumpling, while the protruded cations on BaO(100) shift the VBM in the opposite direction from −4.88 eV to −4.24 eV. Our theoretical calculations consistently illustrate both the differences and similarities in surface polarisation and structural relaxation mechanisms among the three oxides, highlighting the intricate relationship between surface structures and energy-level shifting.

Long-range surface effects on the bulk electrostatic environment

Oxides can have both quadrupolar and polar as well as the nonpolar surfaces discussed above. The catalytic performance of CeO₂ is known to be highly dependent on the crystal

orientation.^[16a,22] For the nonpolar surfaces, in the “Fix” state, each atomic plane is charge neutral, ensuring that the Madelung potentials in deeper planes (bulk) are consistent with those calculated in the three-dimensional (3D) periodic cell, i.e., no long-range polarisation, as seen in CeO₂(110) (Figure 2a). However, quadrupolar (Tasker Type 2) and polar surfaces (Tasker Type 3) have entirely different stacking sequences. Although the net dipole moment remains zero through counterbalanced periodic charges on quadrupolar surfaces (Figure 2c) and appropriate reconstructions^[23] on polar surfaces (Figure 2d–f), the intrinsic higher multipoles along the normal direction of the surface also affect the electrostatic potential. Figure 2g shows the calculated bulk $V_{\text{Mad}}^{\text{O}}$ in CeO₂ under different surface terminations at the “Fix” state, demonstrating that the stacking sequence affects the $V_{\text{Mad}}^{\text{O}}$ deep into the bulk. Typically, the bulk $V_{\text{Mad}}^{\text{O}}$ is elevated by O-terminated surfaces, decreased by Ce-terminated surfaces, and remains unchanged under “fixed” nonpolar terminations. Electronic redistribution and atomic relaxation further affect the bulk potential and usually result in increased $V_{\text{Mad}}^{\text{O}}$ compared with the ideal 21.73 V, which excludes surface effects.

From previous electrostatic analyses, we conclude that surface effects on the energy-level shifting in metal oxides

can be separated into long-range and short-range components. On the one hand, the electrostatic potential varies from the surface to the bulk due to differences in the atomic bonding environment, resulting in short-range band bending near the surface. On the other, long-range surface polarisation affects the bulk energy levels, acting as a voltage that constantly shifts the average electrostatic potential across the slab. In realistic materials with a finite size, the IP and EA measured by experimental techniques are always influenced by surface terminations. Even when measurements are from the deep layers of samples, the energy levels are readily shifted due to long-range surface polarisation. The experimentally measured “bulk” result is therefore a different quantity from the theoretical bulk IP, which, by definition, excludes all surface effects.

Determination of the bulk ionisation potential

The bulk IP is a quantity reflecting the intrinsic electronic structure of a material and is independent of surface terminations. The $V_{\text{Mad}}^{\text{O}}$ calculated within 3D periodicity is such a quantity that indicates the intrinsic electrostatic environment inside a material and determines the band edge

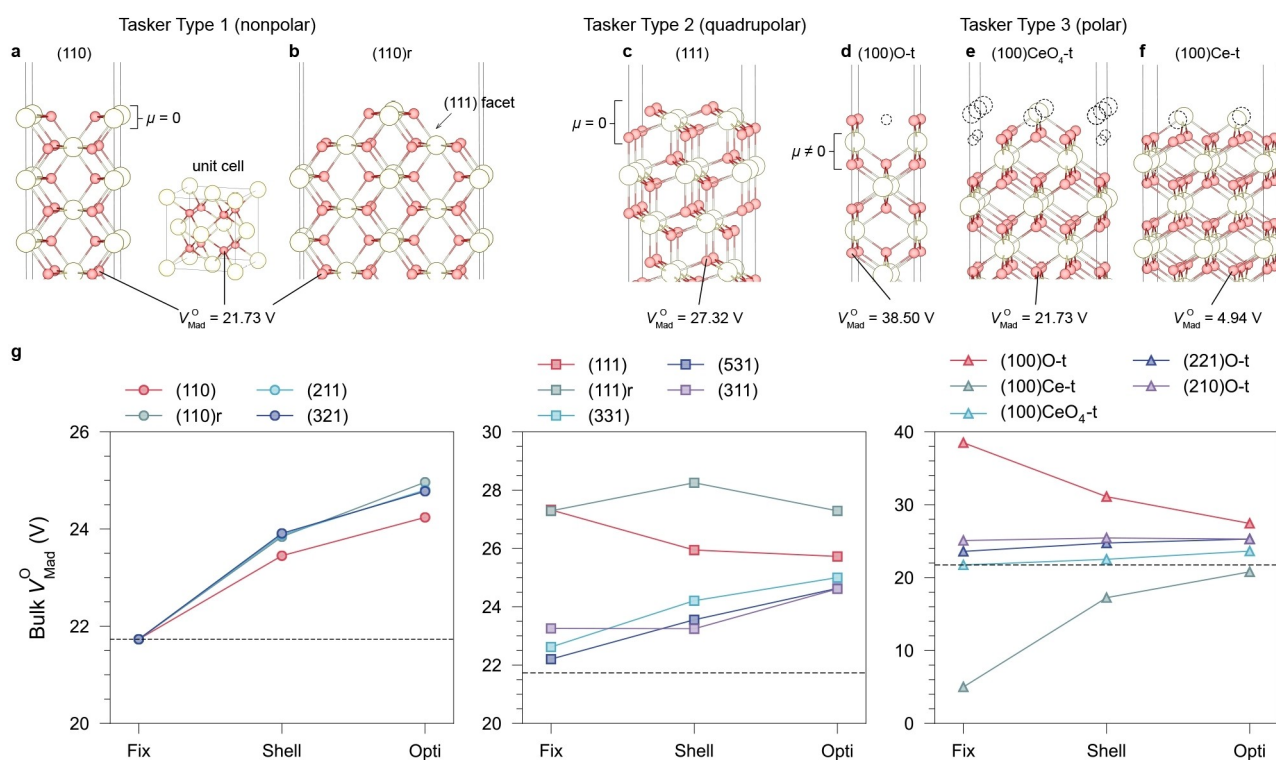


Figure 2. Long-range surface termination effects on the bulk electrostatic potentials in CeO₂. The results are categorised as polar, nonpolar, and quadrupolar surfaces as defined by Tasker.^[15] Slab models of (a) the nonpolar (110) surface and (b) its (2×1) reconstruction, (c) the quadrupolar (111) surface, and (d–f) three different reconstruction patterns of the polar (100) surface with fixed bulk geometry. The dashed circles represent the atomic vacancies due to surface reconstruction. The $V_{\text{Mad}}^{\text{O}}$ values shown below indicate the converged Madelung potential on O sites in the middle of slabs at the “Fix” state, representing the bulk electrostatic environment. (g) Variation of the bulk $V_{\text{Mad}}^{\text{O}}$ under different surface terminations after electronic redistribution (the “Shell” state) and structural relaxation (the “Relax” state). Dash lines represent the $V_{\text{Mad}}^{\text{O}}$ calculated under 3D periodicity that excludes surface effects (21.73 V). The deviations of $V_{\text{Mad}}^{\text{O}}$ from 21.73 V indicate the effect of long-range surface polarisation on varying the bulk electrostatic environment.

positions.^[24] For more accurate electronic-structure calculations, the key to obtaining reliable bulk IPs is to exclude surface effects using appropriate models. The hybrid QM/MM embedded-cluster model (Figure 3a) is the state-of-the-art approach to determining the bulk IP, which reproduces the bulk electrostatic environment in the MM regions, without surface effects, while maintaining access to the vacuum level.^[9,25] Our QM/MM calculations run with the ChemShell code^[26] predict bulk IPs of 5.38 eV, 5.10 eV, 4.99 eV, and 4.92 eV for CeO₂ using the BB1K,^[27] PBE0,^[11] HSE06,^[28] and B97-2^[29] hybrid functionals, respectively. The predictions show a slightly increasing trend with the percentage of Hartree-Fock exchange in hybrid functionals, which is also observed in other oxides (Table S15).^[30] The screening effect considered by HSE06 leads to a slightly

lower calculated IP compared to PBE0 with an equivalent amount of Hartree-Fock exchange (<0.2 eV). The SM-corrected CLA approach also predicts 4.76 eV with a D_s correction of -1.06 eV, in reasonable agreement with QM/MM results. In Figure 3b, we plotted the intrinsic band alignment diagram among several MO₂ oxides with respect to the vacuum level, where the bulk IP is calculated consistently at the BB1K level of theory using the QM/MM approach. This result shows the intrinsic band alignment with a complete exclusion of surface effects.

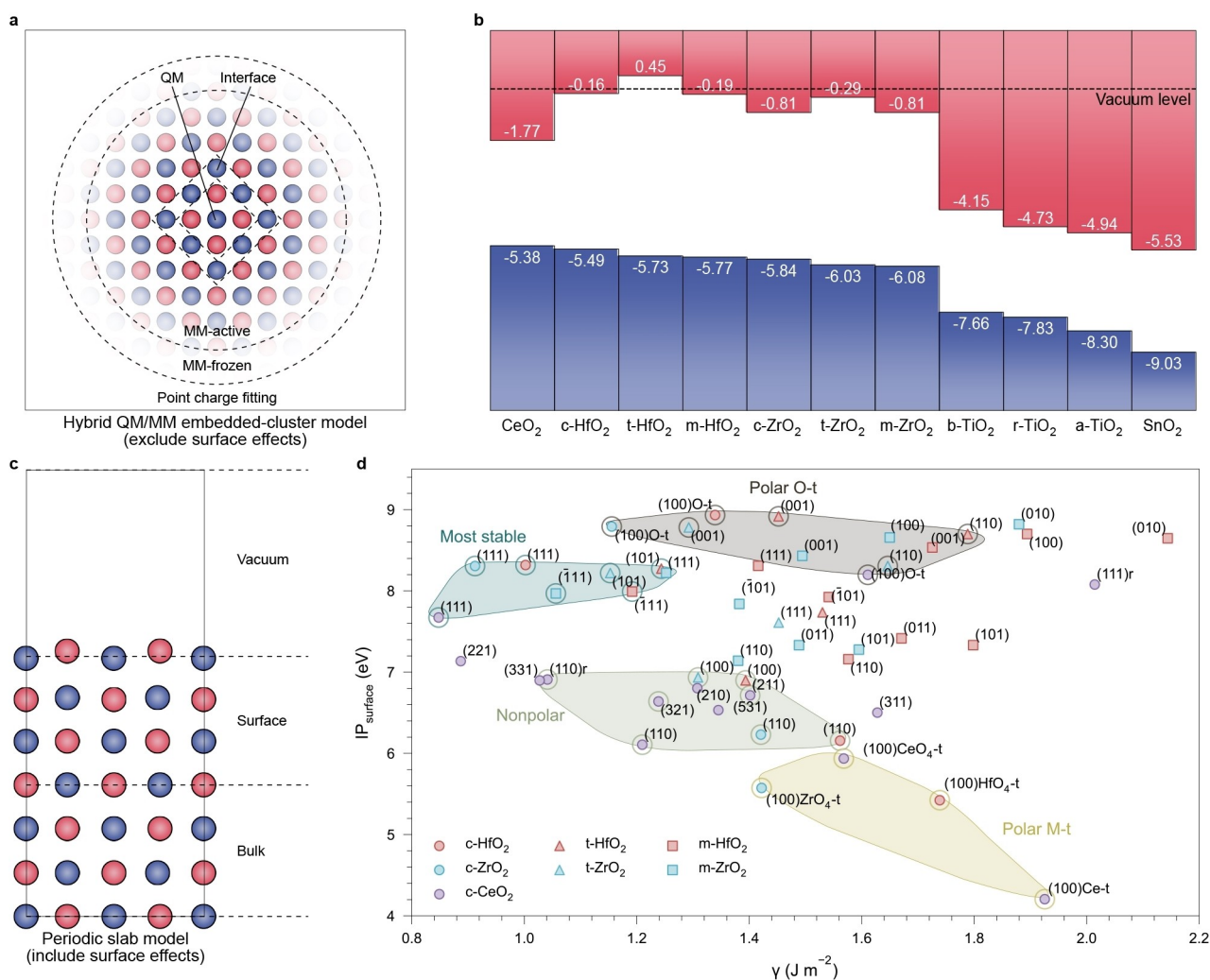


Figure 3. Theoretical approaches for determining the bulk and surface contributions to the ionisation potential of solids and their applications to MO₂ oxides. (a) Hybrid QM/MM embedded-cluster approach that excludes all surface effects for calculating the bulk contribution to the IP. (b) Intrinsic band alignment of MO₂-type oxides with respect to a common reference vacuum level. The valence band alignments are determined by the QM/MM approach at the BB1K level of theory, while positions of conduction band minima (CBM) are determined by adding the theoretical band gaps calculated by the plane-wave DFT approach with the HSE06 functional. Previous results on TiO₂ polymorphs^[25] and SnO₂^[30] are also included. (c) Periodic slab model to calculate the surface-dependent IP. (d) Surface energies and IPs of pristine surfaces of CeO₂, ZrO₂ and HfO₂. Four regions are highlighted in different colours to distinguish the O-terminated polar surfaces, the most stable (quadrupolar) surface in each phase, nonpolar surfaces, and metal-terminated polar surfaces. The scatter points without circle frames are not included in these regions.

Surface-dependence of ionisation potentials

The periodic slab model (Figure 3c) considers both the bulk and surface contributions to the IP that can match the experimentally observed termination dependence.^[31] We calculated the IPs of CeO₂ under different orientations using DFT at the PBE0 level of theory. A comparison with experimental measurements from Wardenga and Klein^[5] is given in Table S18. Unlike rock-salt structured oxides that are dominated by the nonpolar (100) surface, the quadrupolar (111) surface (Figure 2c) is the most stable ($\gamma = 0.85 \text{ J m}^{-2}$) in ceria with a high IP of 7.67 eV (Figure 2c). Wardenga and Klein reported an experimental IP of ca. 7.55 eV for the sample annealed at 700 °C in an O-rich atmosphere, accompanied by 7.7 eV on the stoichiometric sample from Pfau and Schierbaum,^[7a] in excellent agreement with our results.

For the nonpolar CeO₂(110) surface (Figure 2a), experiments on annealed samples observed that half of the surface atoms could be released while retaining surface stoichiometry, forming a terrace-like reconstructed pattern (Figure 2b) composed of zigzagged (111) nanofacets.^[32] We confirmed by DFT calculations that this surface has an energy of 0.17 J m^{-2} lower than the unreconstructed (110) surface, suggesting an energetically favourable transformation at elevated temperatures. Upon reconstruction, the IP increases from 6.11 eV to 6.91 eV, a value lying between those of the standard (110) and (111) surfaces. Wardenga and Klein^[5] reported IPs of (110)-oriented samples from 7.2 to 7.5 eV in O-rich conditions, which could result from the energetically more favourable (111) nanofacets.

The polar CeO₂(100) surface is intrinsically unstable unless appropriately reconstructed. An O-terminated reconstructed pattern (Figure 2d) was first reported to be stabilised by removing half surface oxygen atoms for polarity compensation,^[33] with a calculated surface energy of 1.61 J m^{-2} . Ce-terminated (Figure 2f) CeO₂(100) can also be synthesised on nanocube samples,^[34] although it is energetically less stable ($\gamma = 1.93 \text{ J m}^{-2}$). Recently, López et al.^[35] discovered a pyramid-like CeO₄-terminated configuration (Figure 2e) with a slightly lower surface energy (1.57 J m^{-2}) than the O-t pattern. The O-t (100) surface has the highest calculated IP of 8.20 eV, while IPs of the CeO₄-t and Ce-t reconstructed patterns are much lower (5.94 eV and 4.21 eV, respectively). The experimental IP reported by Wardenga and Klein ranges from 7.6 eV to 8.1 eV prepared in O-rich conditions, where Ce-terminated surfaces are less favourable.

Our current models do not consider the variable stoichiometry of ceria, which can further lead to more significant IP variations beyond the intrinsic surface effects. For example, fully reduced Ce₂O₃ could be considered as the upper limit of non-stoichiometry effects in CeO_{2-x}. Ce₂O₃ has two distinct lattice structures: a hexagonal phase (A-type) and a cubic phase (C-type).^[37] As will be discussed in detail in a future study, the reduction of CeO₂ decreases the bulk $V_{\text{Mad}}^{\text{O}}$ from 21.73 V to 20.7 V in C-Ce₂O₃ (with a calculated lattice constant of 11.200 \AA at the PBE0 level of theory) and 20.10 V in A-Ce₂O₃ ($a = 3.864 \text{ \AA}$ and $c = 6.088 \text{ \AA}$

from PBE0 calculations), indicating a lower bulk contribution to the IPs in reduced phases. Furthermore, the C-Ce₂O₃(111) and A-Ce₂O₃(001) surfaces, which maintain the CeO₂(111) stacking sequence, have IPs of 6.53 eV and 7.19 eV (from O 2*p* states) calculated at the PBE0 level of theory, respectively. Compared with the 7.67 eV IP of CeO₂(111), it can be estimated that variable stoichiometry in CeO_{2-x} could lead to a decrease in IP of up to 1.2 eV. The decrease in IP of CeO_{2-x} with an increasing percentage of Ce³⁺ is also observed experimentally by Wardenga and Klein.^[5]

We further expand our analysis to other MO₂-type high- κ dielectrics, including not only the cubic (*c*-) phase but also the monoclinic (*m*-) and tetragonal (*t*-) phases of ZrO₂ and HfO₂. Like CeO₂, the bulk contributes only 5.5–6.1 eV to their IPs (Figure 3b). Figure 3d shows the calculated IPs as a function of surface energies (Table S7–S9), with four regions highlighted to illustrate the similarity among these oxides. First, the most stable surfaces are all quadrupolar and exhibit relatively high IPs, ranging from the lowest 7.67 eV of CeO₂(111) to the highest 8.32 eV of *c*-HfO₂(111). These results are consistent with experimental measurements using spectroscopic techniques (Table S1–S3), for example, 7.5–7.7 eV for CeO₂(111),^[5,7a] 8.3–8.6 eV for ZrO₂,^[36] and 8.0–8.4 eV for HfO₂,^[37] where the most stable surfaces should be dominant. Next, nonpolar surfaces have much lower IPs, closer to the bulk values due to the lowest net surface dipoles. Then, reconstructions of polar surfaces result in considerable IP differences between the oxygen- and metal-terminated patterns, which cover the highest (8.93 eV for O-t *c*-HfO₂(100)) and lowest (4.21 eV for CeO₂(100)Ce-t) values. The remaining surfaces are mainly quadrupolar with a wide range of IPs and γ due to diverse stacking sequences.

We also calculated IPs for pristine surfaces of rutile (7.09–9.08 eV), anatase (7.20–8.88 eV), and brookite TiO₂ (8.45–9.78 eV), as shown in Table S10. The small cation size in TiO₂ increases the bulk $V_{\text{Mad}}^{\text{O}}$ to ca. 26 V, so that the bulk contribution to their IPs is much higher than CeO₂, HfO₂, and ZrO₂ (Figure 3b). The lower cation polarisability (1.475 a.u.) further eliminates the IP discrepancies under different surface terminations.

Our calculations reveal that the IPs of MO₂-type high- κ oxides are highly sensitive to their surface orientations. Differences in atomic stacking patterns, surface polarisation, and structural relaxation can result in variations of several electron volts in the IP, even for stoichiometric surfaces, which when combined with their variable surface chemistry, account for the uncertainties and controversies in energetic band alignment of metal oxides.^[25a] However, this diversity provides an opportunity to manipulate the band structure to meet specific requirements in technological applications. For instance, considering the close stability of O-t and CeO₄-t CeO₂(100)^[35] and over 2 eV difference in their IPs, their ratio during synthesis might be controlled to optimise the performance in band-edge related chemical processes such as photocatalytic water-splitting and hydration reactions.^[25b,38]

The key role of electrostatics

Figure 4a shows the relationship between the bulk IPs of various metal oxides and $V_{\text{Mad}}^{\text{O}}$, reconfirming the critical role of electrostatics in determining the valence band edges. When multiple bonding environments exist for oxygen, the one with the lowest $V_{\text{Mad}}^{\text{O}}$ becomes the dominant site for ionisation. For example, baddeleyite TiO_2 has a mix of twofold- and fourfold-coordinated O ions with significantly different $V_{\text{Mad}}^{\text{O}}$ (21.15 V and 29.78 V, respectively). The calculated bulk IP is much lower (4.77 eV) than that of other TiO_2 phases, and the anions at twofold-coordinated sites are the preferential site for ionisation.^[25b] Despite considerable differences in oxidation states and crystal structures among these oxides, the classical treatment using Madelung potential shows the ability to predict variations in the bulk IP with reasonable accuracy. Surface IPs also correlate linearly with $V_{\text{Mad}}^{\text{O}}$ within a specific material. Slab models of CeO_2 surfaces and their reconstructed configurations were employed to calculate the IPs and $V_{\text{Mad}}^{\text{O}}$ at surface O sites based on the

SM. As shown in Figure 4b, the linear regression results in $\text{IP}_{\text{surface}} = 0.976eV_{\text{Mad}}^{\text{O}} - 16.139 \text{ eV}$, with a coefficient of determination R^2 of 0.964, indicating that electrostatic interaction also determines surface band edge positions. As shown in Table S12, on most surfaces, the surface Ce atoms move further inwards into the bulk compared to oxygen, resulting in increased $V_{\text{Mad}}^{\text{O}}$, and thus all stable O-terminated surfaces of CeO_2 contribute to a higher IP than the bulk. Additionally, except for (100)Ce-t, the difference between the surface and bulk $V_{\text{Mad}}^{\text{O}}$ is negative, indicating an upward valence band bending near the surfaces.

The Madelung potential in metal oxides can be easily calculated using lattice energy codes such as GULP^[14] based on the given atomic structure and charge states. The linear relationship could also be used to assess the IPs of unknown systems with complex atomic structures. To further explore the interplay between the IPs of oxides with the properties of their constitutional ions, we calculated the bulk $V_{\text{Mad}}^{\text{O}}$ in 91 common binary oxides from Li_2O to PuO_2 within the point-charge approximation, combined with gas-phase cation

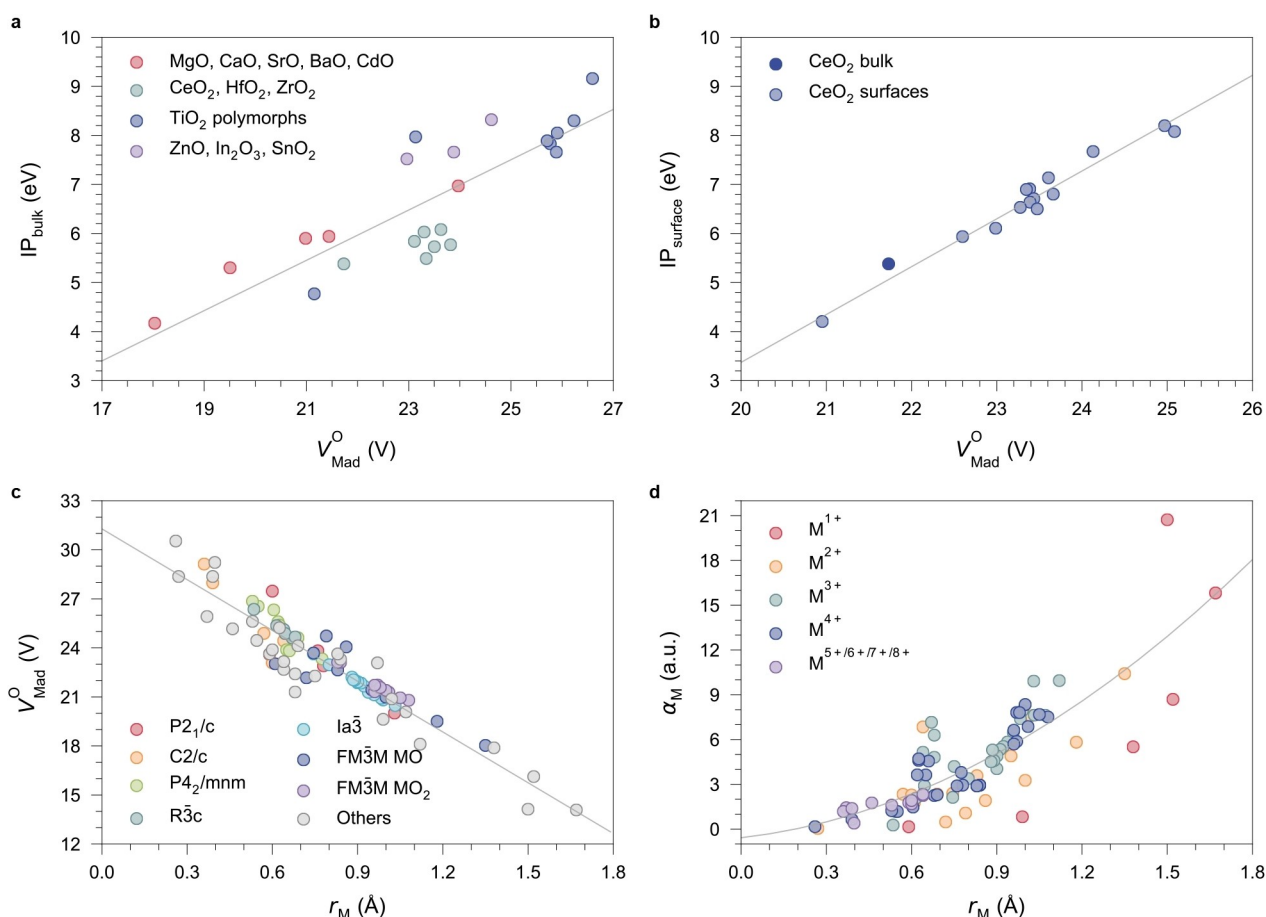


Figure 4. Impacts of the electrostatic environment and cation properties on the IPs of oxide materials. (a) Bulk IPs of various oxide materials as a function of the lowest in-crystal Madelung potential on O sites ($V_{\text{Mad}}^{\text{O}}$). The bulk IPs of the rock-salt structured oxides (MgO, CaO, SrO, BaO, and CdO) were previously determined by the SM-corrected CLA method.^[19] Other data are calculated by the QM/MM approach at the BBTK level of theory, including transparent conducting oxides (ZnO, In₂O₃, and SnO₂),^[30] TiO₂ polymorphs,^[25] and CeO₂, HfO₂, and ZrO₂ from this work. (b) Surface IPs (calculated by periodic slab models) of CeO₂ as a function of $V_{\text{Mad}}^{\text{O}}$ and Shannon effective radii^[12] of cations (r_{M}) in various binary oxides. (c) The relationship between $V_{\text{Mad}}^{\text{O}}$ and Shannon effective radii^[12] of cations (r_{M}) in various binary oxides. (d) The relationship between cation polarisability (α_{M}) and r_{M} . Cations with the same formal charge states are shown using the same colour, and those with rare high oxidation states (M⁵⁺, M⁶⁺, M⁷⁺, and M⁸⁺) are shown together.

polarisabilities calculated at the PBE0 level of theory. The full dataset is given in Table S19. Figure 4c shows the relationship of $V_{\text{Mad}}^{\text{O}}$ with Shannon ionic radii.^[12] We observed that, as expected, $V_{\text{Mad}}^{\text{O}}$ correlates in a reverse linear relationship with cation size. Therefore, oxides constituted with larger cations usually have lower $V_{\text{Mad}}^{\text{O}}$ and are expected to have lower bulk contributions to their IPs. However, as the size increases, the cation polarisability also becomes higher (Figure 4d). As a result, metal oxides with large cations are also expected to have higher surface contributions to their IPs because of the enhanced surface polarisation from cations. These conclusions could be extended to MO_2 - and M_2O_3 -type lanthanide and actinide oxides, where their IP is unknown. However, these oxides have similarly low bulk $V_{\text{Mad}}^{\text{O}}$ (ranging from 18.11 V of Ac_2O_3 to 22.21 V of Lu_2O_3) and relatively high cation polarisabilities (ranging from 4.17 a.u. of Lu^{3+} to 9.95 a.u. of Ac^{3+}) as CeO_2 , thus should also show significant variations in the IPs under different surface terminations.

Conclusion

Our study has deconvoluted the bulk and surface contributions to IPs of metal oxides using a range of theoretical techniques, emphasising the pivotal role of the electrostatic environment in determining the band edge positions. Our results reveal that apart from the well-known near-surface band bending, long-range surface polarisation can significantly affect the absolute energy levels deep into the bulk, explaining the fundamental origins of IP variations in experimental measurements. We determined the bulk contribution to the IPs of CeO_2 , HfO_2 , and ZrO_2 to be only 5.38–6.08 eV, while changing surface orientations can result in significant IP variations of several electron volts. Rational exploitation of these relationships could benefit the design of novel photovoltaic and electronic devices towards higher efficiencies.

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Conflict of Interest

The authors declare no conflict of interest.

Data Availability Statement

The data that support the findings of this study are available from the corresponding author upon reasonable request.

Keywords: Ceria · Ionization Potential · Metal Oxides · QM/MM · Surface Chemistry

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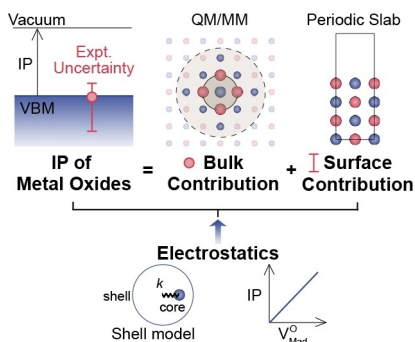
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Research Articles

Metal Oxides

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Bulk and Surface Contributions to Ionisation Potentials of Metal Oxides



Using a combination of theoretical techniques, we separated the bulk and surface contributions of ionisation potentials of metal oxides, highlighting the critical role of electrostatics. Low bulk ionisation potentials and a high degree of tunability from surfaces were found in CeO_2 , HfO_2 , and ZrO_2 , explaining the discrepancies from measurements and guiding the future design of band-edge-related photocatalytic, photovoltaic, and electrochemical devices.